







an Open Access Journal by MDPI

Nitride Nanostructures: Growth Methods and Device Applications

Guest Editor:

Dr. Xiaowei Zhou

School of Advanced Materials and Nanotechnology, Xidian University, Xi'an 710071, China

Deadline for manuscript submissions:

20 February 2025

Message from the Guest Editor

This journal focuses on the scientific and engineering aspects of **III**-nitride materials and **III**-nitrides combined with two-dimensional materials, the description of unprecedented physical phenomena that can be observed in the fundamental properties of materials, material growth techniques, device structure design, and the realization of state-of-the-art electronic devices.

- **III**-nitride materials growth;
- Defect control:
- Doping efficiency:
- Device design;
- Reliability analysis;
- **III**-nitride combination with two-dimensional materials.

We look forward to receiving insightful contributions.











an Open Access Journal by MDPI

Editor-in-Chief

Prof. Dr. Shirley Chiang

Department of Physics, University of California Davis, One Shields Avenue, Davis, CA 95616-5270, USA

Message from the Editor-in-Chief

Nanoscience and nanotechnology are exciting fields of research and development, with wide applications to electronic, optical, and magnetic devices, biology, medicine, energy, and defense. At the heart of these fields are the synthesis, characterization, modeling, applications of new materials with lower nanometer-scale dimensions, which we call "nanomaterials". These materials can exhibit unusual mesoscopic properties and include nanoparticles, coatings and thin films, metalorganic frameworks, membranes, nano-alloys, quantum dots, self-assemblies, 2D materials such as graphene, and nanotubes. Our journal, Nanomaterials, has the goal of publishing the highest quality papers on all aspects of nanomaterial science to an interdisciplinary scientific audience. All of our articles are published with rigorous refereeing and open access.

Author Benefits

Open Access: free for readers, with article processing charges (APC) paid by authors or their institutions.

High Visibility: indexed within Scopus, SCIE (Web of Science), PubMed, PMC, CAPlus / SciFinder, Inspec, and other databases.

Journal Rank: JCR - Q2 (*Chemistry, Multidisciplinary*) / CiteScore - Q1 (General Chemical Engineering)

Contact Us